

**Amendments to the Claims:**

Please amend claims 4, 10-12, 15, 19-21, 27, 28, 34-36, 51, 56-60, 64, 65, 70 and 71 as follows. Following is a complete listing of the claims pending in the application, as amended:

1. (Cancelled)

2. (Cancelled)

3. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

selecting first and second conductive electrodes to have a combined surface area facing toward a surface of the microelectronic substrate that is less than the area of the surface of the microelectronic substrate;

positioning the first conductive electrode proximate to the microelectronic substrate;

positioning the second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode;

removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate; and

moving at least one of the microelectronic substrates and the electrodes relative to the other while applying an electrical current to the at least one electrode.

4. (Currently Amended) The method of claim 43, further comprising disposing a liquid and/or gel electrolyte between the electrodes and the microelectronic substrate.

5. (Cancelled)

6. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to the microelectronic substrate;

positioning a second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode;

removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate; and

varying an amplitude and/or polarity of the current at a first frequency and superimposing on the first frequency an amplitude variation having a second frequency less than the first frequency.

7. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate having a planform shape, the method comprising:

selecting a first conductive electrode to have a planform shape generally similar to a first portion of the planform shape of the microelectronic substrate and selecting a second conductive electrode to have a planform shape generally similar to a second portion of the planform shape of the microelectronic substrate;

positioning the first conductive electrode proximate to the microelectronic substrate;

positioning the second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode; and

removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes while the first and

second electrodes are spaced apart from the conductive material of the microelectronic substrate.

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*DI*  
8. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to the microelectronic substrate;

positioning a second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode, the first and second electrodes defining a first electrode pair;

removing a first portion of the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate;

positioning a second electrode pair proximate to the microelectronic substrate;  
and

applying a varying current to the second electrode pair to remove a second portion of conductive material from the microelectronic substrate.

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9. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to the microelectronic substrate;

positioning a second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode;

removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate, the varying current including at least one of a single phase and a multi-phase alternating current.

10. (Currently Amended) The method of claim 34 wherein the microelectronic substrate has a surface facing toward the first and second electrodes, further comprising selecting the first and second electrodes to have a combined surface area facing toward the surface of the microelectronic substrate that is approximately equal to the surface of the microelectronic substrate.

11. (Currently Amended) The method of claim 43, further comprising controlling a rate at which the conductive material is removed from the microelectronic substrate by controlling a distance between at least one of the electrodes and the microelectronic substrate.

12. (Currently Amended) The method of claim 34, further comprising controlling a rate at which the conductive material is removed from the microelectronic substrate by spacing a first portion of the first electrode a first distance away from a first region of the microelectronic substrate and spacing a second portion of the first electrode a second distance away from a second region of the electrode with the first distance being different than the second distance.

13. (Cancelled)

14. (Cancelled)

15. (Currently Amended) The method of claim 34, further comprising:  
at least partially immersing the microelectronic substrate in a liquid electrolyte;  
moving portions of the electrically conductive material from the microelectronic substrate to the liquid electrolyte; and  
removing the portions from the liquid electrolyte.

16. (Cancelled)

17. (Cancelled)

18. (Cancelled)

19. (Currently Amended) The method of claim 34, further comprising:  
disposing a first quantity of an electrolyte between the conductive material and  
the electrodes only in a first region of the microelectronic substrate  
immediately proximate to the electrodes;  
moving the microelectronic substrate and/or the electrodes to align a second  
region of the microelectronic substrate with the electrodes; and  
disposing a second quantity of the electrolyte between the conductive material  
and the electrodes only in the second region of the microelectronic  
substrate.

20. (Currently Amended) The method of claim 34, further comprising:  
disposing a first electrolyte adjacent to the first electrode;  
disposing a second electrolyte different than the first electrolyte adjacent to the  
conductive material of the microelectronic substrate; and  
at least restricting movement of the second electrolyte toward the first electrode.

21. (Currently Amended) The method of claim 34, further comprising:  
generating a signal corresponding to a rate at which the conductive material is  
removed from the microelectronic substrate and/or an amount of  
conductive material remaining on the microelectronic substrate; and  
controlling an interaction between the microelectronic substrate and the  
electrodes based on the input signal.

22. (Previously Presented) A method for removing an electrically conductive  
material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to the microelectronic  
substrate;

positioning a second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode;  
removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate; and  
at least restricting contact between the first electrode and a liquid adjacent to the first conductive material of the microelectronic substrate by disposing a dielectric film between the first electrode and the liquid.

23. (Cancelled)

24. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to the microelectronic substrate;

positioning a second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode;

removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes without contacting the first and second electrodes directly with the conductive material of the microelectronic substrate; and

varying an amplitude and/or polarity of the current at a first frequency and superimposing on the first frequency an amplitude variation having a second frequency less than the first frequency.

25. (Previously Presented) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to the microelectronic substrate;

*Spb*  
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positioning a second conductive electrode proximate to the microelectronic substrate and spaced apart from the first conductive electrode, the first and second electrodes defining a first electrode pair; and  
removing the conductive material from the microelectronic substrate by passing a varying current through the first and second electrodes without contacting the first and second electrodes directly with the conductive material of the microelectronic substrate;  
positioning a second electrode pair proximate to the microelectronic substrate; and  
applying a varying current to the second electrode pair to remove a second portion of conductive material from the microelectronic substrate.

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26. (Cancelled)

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*D1*

27. (Currently Amended) The method of claim 2423, further comprising:  
disposing a first quantity of an electrolyte between the conductive material and the electrodes only in a first region of the microelectronic substrate immediately proximate to the electrodes;  
moving the microelectronic substrate and/or the electrodes to align a second region of the microelectronic substrate with the electrodes; and  
disposing a second quantity of the electrolyte between the conductive material and the electrodes only in the second region of the microelectronic substrate.

28. (Currently Amended) The method of claim 2423, further comprising:  
disposing a first electrolyte adjacent to the first electrode;  
disposing a second electrolyte different than the first electrolyte adjacent to the conductive material of the microelectronic substrate; and  
at least restricting movement of the second electrolyte toward the first electrode.

29. (Cancelled)

30. (Cancelled)

31. (Cancelled)

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*SCR*  
*DI*  
*CL*

32. (Previously Presented) A method for forming a planarizing medium, comprising:

forming a planarizing pad body having a planarizing surface to engage a surface of a microelectronic substrate;

disposing a first electrode at least adjacent to the planarizing pad body and spaced apart from the planarizing surface with the first electrode coupleable to a source of varying current;

disposing a second electrode at least adjacent to the planarizing pad body with the second electrode spaced apart from the first electrode;

disposing a dielectric material between the first and second electrodes; and

disposing a dielectric film between the planarizing surface and the electrodes.

33. (Cancelled)

34. (Currently Amended) The method of claim 2033 wherein at least restricting motion of the second electrolyte includes disposing a permeable membrane between the one electrode and the microelectronic substrate and passing the first electrolyte through the membrane.

35. (Currently Amended) The method of claim 2033, further comprising selecting the first electrolyte to include sodium chloride, potassium chloride, and/or or copper sulfate.

36. (Currently Amended) The method of claim 2033, further comprising selecting the second electrolyte to include hydrochloric acid.

37. (Original) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode proximate to a first portion of the microelectronic substrate;  
positioning a second conductive electrode proximate to the first portion of microelectronic substrate and spaced apart from the first conductive electrode, the first and second electrodes defining an electrode pair;  
removing the conductive material from the first portion of the microelectronic substrate by passing a varying current through the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate;  
moving at least one of the microelectronic substrate and the electrode pair relative to the other to align a second portion of the microelectronic substrate with the electrode pair; and  
removing the conductive material from the second portion of the microelectronic substrate by applying a varying current to at least one of the first and second electrodes while the first and second electrodes are spaced apart from the conductive material of the microelectronic substrate.

38. (Original) The method of claim 37, further comprising:

directing a first flow of electrolyte only to the first portion of the microelectronic substrate when the electrode pair is proximate to the first portion; and  
directing a second flow of electrolyte only to the second portion of the microelectronic substrate when the electrode pair is proximate to the second portion.

39. (Cancelled)

40. (Cancelled)

41. (Cancelled)

42. (Cancelled)

43. (Original) A method for removing an electrically conductive material from a microelectronic substrate, comprising:

positioning a first conductive electrode at least proximate to a first portion of the microelectronic substrate;

positioning a second conductive electrode at least proximate to the first portion of the microelectronic substrate and spaced apart from the first conductive electrode, the first and second electrodes defining a first electrode pair;

positioning a second electrode pair at least proximate to a second portion of the microelectronic substrate, the second electrode pair including a third electrode and a fourth electrode spaced apart from the third electrode; and

removing the conductive material from the microelectronic substrate by passing a first varying current through the first and second electrodes and passing a second varying current through the third and fourth electrodes.

44. (Original) The method of claim 43, further comprising spacing the first and second electrodes apart from the microelectronic substrate while applying the first varying current.

45. (Original) The method of claim 43, further comprising spacing the first electrode pair a first distance from a surface of the microelectronic substrate and spacing the second electrode pair a second distance from the surface of the microelectronic substrate with the first distance greater than the second distance.

46. (Original) The method of claim 43, further comprising:

spacing the first and second electrode pair apart from each other by a first distance;

*Sub D*

spacing a third and fourth electrode pair apart from each other by a second distance greater than the first distance, with each of the third and fourth electrode pairs including two spaced apart electrodes;

aligning the third electrode pair with a third portion of the microelectronic substrate and aligning the fourth electrode pair with a fourth portion of the microelectronic substrate; and

removing the conductive material from the third and fourth portions of the microelectronic substrate by passing a third varying current through the third electrode pair and passing a fourth varying current through the fourth electrode pair.

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47. (Original) The method of claim 43 wherein the first varying current is approximately identical to the second varying current.

48. (Original) The method of claim 43 wherein an amplitude of the first varying current is greater than an amplitude of the second varying current.

49. (Cancelled)

50. (Cancelled)

51. (Currently Amended) The apparatus of claim 5649, further comprising an electrolyte vessel configured to support a liquid electrolyte, and further wherein the support member is positioned relative to the electrolyte vessel to support the microelectronic substrate within the vessel.

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52. (Previously Presented) An apparatus for removing conductive material from a microelectronic substrate, comprising:

a support member having at least one engaging surface to support the microelectronic substrate;

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- a first electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member;
- a second electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member, the second electrode being spaced apart from the first electrode, at least one of the first and second electrodes being coupleable to a source of varying current; and
- a dielectric layer at least proximate to the first electrode, the dielectric layer being positioned between the microelectronic substrate and the first electrode when the microelectronic substrate is supported by the support member.

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53. (Previously Presented) An apparatus for removing conductive material from a microelectronic substrate, comprising:

- a support member having at least one engaging surface to support the microelectronic substrate;
- a first electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member;
- a second electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member, the second electrode being spaced apart from the first electrode; and
- a current source configured to vary an amplitude of the current at a first frequency, the current source including an amplitude modulator to superimpose on the first frequency an amplitude and/or polarity variation having a second frequency less than the first frequency, wherein at least one of the first and second electrodes is coupleable to the current source.

54. (Cancelled)

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55. (Previously Presented) An apparatus for removing conductive material from a microelectronic substrate, comprising:

- a support member having at least one engaging surface to support the microelectronic substrate;
- a first electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member;
- a second electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member, the second electrode being spaced apart from the first electrode, the first and second electrodes defining a first electrode pair, at least one of the first and second electrodes being coupleable to a source of varying current;
- a third electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member; and
- a fourth electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member, the fourth electrode being spaced apart from the third electrode, at least one of the third and fourth electrodes being coupleable to a source of varying current.

56. (Currently Amended) An apparatus for removing conductive material from a microelectronic substrate, comprising:

- a support member having at least one engaging surface to support the microelectronic substrate;
- a first electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member; and

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a second electrode spaced apart from the support member and from the microelectronic substrate when the microelectronic substrate is supported by the support member, the second electrode being spaced apart from the first electrode, the first and second electrodes being positioned to pass electrical current through a current path that includes the first and second electrodes and the microelectronic substrate when the microelectronic substrate is supported by the support member; and

a current source that includes a single phase or a multi-phase alternating current supply, wherein at least one of the first and second electrodes is coupleable to the current source.

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57. (Currently Amended) The apparatus of claim 5649 wherein the microelectronic substrate has a surface facing toward the first and second electrodes, and further wherein the first and second electrodes have a combined surface area facing toward the surface of the microelectronic substrate that is approximately equal to the surface area of the microelectronic substrate.

58. (Currently Amended) The apparatus of claim 5649 wherein the microelectronic substrate has a surface facing toward the first and second electrodes, and further wherein the first and second electrodes have a combined surface area facing toward the surface of the microelectronic substrate that is less than the area of the surface of the microelectronic substrate, at least one of the microelectronic substrate and the electrodes being moveable relative to the other while an electrical current is applied to the ~~at least one~~ electrode.

59. (Currently Amended) The apparatus of claim 5649 wherein the first and second electrodes define an electrode pair, further wherein at least one of the electrode pair and the support member is moveable toward and away from the other to control a distance between the electrode pair and the microelectronic substrate when the microelectronic substrate is supported by the support member.

60. (Currently Amended) The apparatus of claim 5649 wherein at least one of the first electrode and the support member is movable relative to the other and the first electrode includes a first surface portion and a second surface portion, the first and second surface portions facing the microelectronic substrate when the microelectronic substrate is supported by the support member, the first portion being positioned further from the microelectronic substrate than the second portion when a first region of the microelectronic substrate opposite the first portion has a slower velocity relative to the first electrode than does a second region of the microelectronic substrate opposite the second portion of the first electrode.

61. (Cancelled)

62. (Cancelled)

63. (Cancelled)

64. (Currently Amended) The apparatus of claim 5649, further comprising a sensor positioned at least proximate to the support member to detect a rate at which the conductive material is removed from the microelectronic substrate and/or an amount of conductive material remaining on the microelectronic substrate.

65. (Currently Amended) The apparatus of claim 5649, further comprising:

~~the current source coupled to the at least one electrode; and~~

a sensor positioned at least proximate to the support member to detect a rate at which the conductive material is removed from the microelectronic substrate and/or an amount of conductive material remaining on the microelectronic substrate, the sensor being coupled to the current source and/or at least one of the electrodes to control an electrical potential imparted to the microelectronic substrate when the microelectronic substrate is supported by the support member.

66. (Cancelled)

67. (Cancelled)

68. (Previously Presented) An apparatus for removing a conductive material from a microelectronic substrate, comprising:

a carrier having at least one engaging surface to support a microelectronic substrate;

a polishing pad proximate to the carrier and having a polishing surface to engage the microelectronic substrate, at least one of the polishing pad and the carrier being movable relative to the other;

a first electrode proximate to the polishing surface; and

a second electrode proximate to the polishing surface and spaced apart from the first electrode; and

a current source configured to vary an amplitude of the current at a first frequency, further wherein the current source includes an amplitude modulator to superimpose on the first frequency an amplitude and/or polarity variation having a second frequency less than the first frequency, and wherein at least one of the first and second electrodes is coupleable to the current source.

69. (Previously Presented) An apparatus for removing a conductive material from a microelectronic substrate, comprising:

a carrier having at least one engaging surface to support a microelectronic substrate;

a polishing pad proximate to the carrier and having a polishing surface to engage the microelectronic substrate, at least one of the polishing pad and the carrier being movable relative to the other;

a first electrode proximate to the polishing surface;

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a second electrode proximate to the polishing surface and spaced apart from the first electrode, at least one of the first and second electrodes being coupleable to a source of varying electrical current, the first and second electrodes defining a first electrode pair;

a third electrode spaced apart from the carrier and from the microelectronic substrate when the microelectronic substrate is supported by the carrier; and

a fourth electrode spaced apart from the carrier and from the microelectronic substrate when the microelectronic substrate is supported by the carrier, the fourth electrode being spaced apart from the third electrode, at least one of the third and fourth electrodes being coupleable to a source of varying current.

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70. (Currently Amended) The method of claim 6866, further comprising:  
~~the current source coupled to the at least one electrode; and~~  
a sensor positioned at least proximate to the support member to detect a rate at which the conductive material is removed from the microelectronic substrate and/or an amount of conductive material remaining on the microelectronic substrate, the sensor being coupled to the current source and/or at least one of the electrodes to control an electrical potential imparted to the microelectronic substrate when the microelectronic substrate is supported by the carrier.

71. (Currently Amended) ~~The~~<sup>An</sup> apparatus of claim 56, further for removing an electrically conductive material from a microelectronic substrate, comprising:  
~~a support member having an engaging surface to support the microelectronic substrate;~~  
~~a first conductive electrode spaced apart from the support member and spaced apart from the microelectronic substrate when the microelectronic substrate is supported by the support member;~~

~~a second conductive electrode spaced apart from the support member and the first conductive electrode, at least one of the first and second electrodes being coupleable to a source of varying current; and~~  
~~an electrolyte flow restrictor positioned between the support member and at least one of the conductive electrodes to at least restrict a flow of an electrolyte toward at least one of the first and second electrodes.~~

72. (Original) The apparatus of claim 71, further comprising:

a first electrolyte adjacent to the microelectronic substrate and selected from sodium chloride, potassium chloride and copper sulfate; and  
a second electrolyte adjacent to at least one of the electrodes and selected to include hydrochloric acid.

73. (Original) The apparatus of claim 71 wherein the flow restrictor includes a permeable membrane.

74. (Cancelled)

75. (Cancelled)

76. (Original) An apparatus for removing an electrically conductive material from a microelectronic substrate, comprising:

a support member having at least one engaging surface to support the microelectronic substrate;

first and second conductive electrodes spaced apart from each other and defining a first electrode pair, the first electrode pair being at least proximate to the microelectronic substrate when the microelectronic substrate is supported by the support member, at least one of the first and second electrodes being coupleable to a source of varying current; and

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*DL*

third and fourth conductive electrodes spaced apart from each other and defining a second electrode pair spaced apart from the first electrode pair, the second electrode pair being at least proximate to the microelectronic substrate when the microelectronic substrate is supported by the support member, at least one of the third and fourth electrodes being coupleable to a source of varying current.

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77. (Original) The apparatus of claim 76 wherein the first and second electrodes are positioned to be spaced apart from the microelectronic substrate when the microelectronic substrate is supported by the support member.

78. (Original) The apparatus of claim 76 wherein the first electrode pair is positioned a first distance from a surface of the microelectronic substrate and the second electrode pair is positioned a second distance from the surface of the microelectronic substrate when the support member supports the microelectronic substrate, with the first distance greater than the second distance.

79. (Original) The apparatus of claim 76, further comprising a third and fourth electrode pair, the third and fourth electrode pairs each including two spaced apart electrodes, the first and second electrode pair spaced apart from each other by a first distance and the third and fourth electrode pair spaced apart from each other by a second distance greater than the first distance.

80. (Original) The apparatus of claim 76 wherein an amplitude of varying current supplied to the first and second electrodes is different than an amplitude of varying current supplied to the third and fourth electrodes.

81. (Original) The apparatus of claim 76 wherein a frequency of varying current supplied to the first and second electrodes is higher than a frequency of varying current supplied to the third and fourth electrodes.